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- (iii) Any manufacture or import for any use of any chemical substance listed in Table 3 of paragraph (a)(1) of this section, except as noted in paragraphs (a)(3) through (a)(5) of this section.
- (3) Manufacture or import of any chemical substance listed in Table 2 and Table 3 of paragraph (a)(1) of this section for the following specific uses shall not be considered as a significant new use subject to reporting under this section:
- (i) Use as an anti-erosion additive in fire-resistant phosphate ester aviation hydraulic fluids.
- (ii) Use as a component of a photoresist substance, including a photo acid generator or surfactant, or as a component of an anti-reflective coating, used in a photomicrolithography process to produce semiconductors or similar components of electronic or other miniaturized devices.
- (iii) Use in coating for surface tension, static discharge, and adhesion control for analog and digital imaging films, papers, and printing plates, or as a surfactant in mixtures used to process imaging films.
- (iv) Use as an intermediate only to produce other chemical substances to be used solely for the uses listed in paragraph (a)(3)(i), (ii), or (iii) of this section.
- (4) Manufacture orimport tetraethylammonium perfluorooctanesulfonate (CAS 56773-42-3) for use as a fume/mist suppressant in metal finishing and plating baths shall not be considered as a significant new use subject to reporting under this section. Examples of such metal finishing and plating baths include: Hard chrome plating; decorative chromium plating; chromic acid anodizing; nickel, cadmium, or lead plating; metal plating on plastics; and alkaline zinc plating.
- (5) Manufacture or import of: 1-Pentanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,5-undecafluoro-, potassium salt (CAS No. 3872–25–1); Glycine, N-ethyl-N-[(tridecafluorohexyl)sulfonyl]-, potassium salt (CAS No. 67584–53–6); Glycine, N-ethyl-N-

[(pentadecafluoroheptyl)sulfonyl]-, potassium salt (CAS No. 67584-62-7); 1-Heptanesulfonic acid,

1,1,2,2,3,3,4,4,5,5,6,6,7,7,7-pentadecafluoro-,ammonium salt (CAS No. 68259-07-4); 1-Heptanesulfonamide, N-ethyl-1,1,2,2,3,3,4,4,5,5,6,6,7,7,7-pentadecafluoro- (CAS No. 68957-62-0); Poly(oxy-1,2-ethanediyl), .alpha.-[2-

Poly(oxy-1,2-ethanediy), .aipna.-[2-[ethyl[(pentadecafluoroheptyl)sulfonyl] amino]ethyl]-.omega.-methoxy- (CAS No. 68958-60-1); or 1-Hexanesulfonic acid, 1,1,2,2,3,3,4,4,5,5,6,6,6-tridecafluoro-, compd. with 2,2'-iminobis[ethanol] (1:1) (CAS No. 70225-16-0) for use as a component of an etchant, including a surfactant or fume suppressant, used in the plating process to produce electronic devices shall not be considered a significant new use subject to reporting under this section.

(b) [Reserved]

 $[67\ {\rm FR}\ 72863,\ {\rm Dec.}\ 9,\ 2002,\ {\rm as}\ {\rm amended}\ {\rm at}\ 72\ {\rm FR}\ 57229,\ {\rm Oct.}\ 9,\ 2007]$

§ 721.9595 Alkyl benzene sulfonic acids and alkyl sulfates, amine salts (generic).

- (a) Chemical substance and significant new uses subject to reporting. (1) The chemical substances identified generically as alkyl benzene sulfonic acids and alkyl sulfates, amine salts (PMNs P-97-296/297/298/299) are subject to reporting under this section for the significant new uses described in paragraph (a)(2) of this section.
 - (2) The significant new uses are:
- (i) Release to water. Requirements as specified in 721.90 (a)(1), (b)(1), and (c)(1).
 - (ii) [Reserved]
- (b) Specific requirements. The provisions of subpart A of this part apply to this section except as modified by this paragraph.
- (1) Recordkeeping. Recordkeeping requirements as specified in §721.125 (a), (b), (c), and (k) are applicable to manufacturers, importers, and processors of these substances.
- (2) Limitations or revocation of certain notification requirements. The provisions of §721.185 apply to this section.

[63 FR 44582, Aug. 20, 1998]

§ 721.9597 Salt of a substituted sulfonated aryl azo compound (generic).

(a) Chemical substance and significant new uses subject to reporting. (1) The